PLASMA PROCESSING APPARATUS AND PLASMA PROCESSING APPARATUS INNER MEMBER

ABSTRACT

A plasma processing apparatus includes: a plasma processing apparatus inner member, in which the plasma processing apparatus inner member includes a gas supply path and a forming portion in which the gas supply path is formed, when the gas supply path has a representative length d_1 and a longest length d_2 in a cross-section perpendicular to a longitudinal direction of the gas supply path, the representative length d_1 is 0.5 mm or less, a ratio d_2/d_1 of the longest length d_2 to the representative length d_1 is 2 or more, the other end is not visible from one end in a plan view, and the forming portion has a thickness of 2 mm or more.

Figure 3